

Title (en)

METHOD AND DEVICE FOR CONDITIONING A PROCESS

Title (de)

VERFAHREN UND VORRICHTUNG ZUM KONDITIONIEREN EINES PROZESSES

Title (fr)

PROCEDE ET DISPOSITIF DE CONDITIONNEMENT D'UN PROCESSUS

Publication

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Application

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Priority

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Abstract (en)

[origin: WO2005040471A1] The aim of the invention is to be able to condition a process region. To this end, at least one conditioning gas flow (2) is supplied to the process region, said flow consisting of at least one primary gas flow (3) and at least one secondary gas flow (4). The secondary gas flow essentially completely surrounds the primary gas flow, and the primary gas flow has a higher flow speed than the secondary gas flow, at least on average.

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